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10 MAY 2001

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PATENT
2804-0102P

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IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: *28.1* MORISHITA et al. Conf.: Unknown
Appl. No.: 09/787,877 Group: Unknown
Int'l. Appl. No.: PCT/JP99/05231 Examiner: Unknown
Filed: March 23, 2001
For: SEMICONDUCTOR SUBSTRATE AND PRODUCTION
METHOD THEREOF, SEMICONDUCTOR DEVICE USING
THE SAME AND PRODUCTION METHOD THEREOF

RECEIVED
JUN 18 2001
TC 2800 MAIL ROOMLETTERAssistant Commissioner for Patents
Washington, DC 20231

May 10, 2001

Sir:

Subsequent to the filing of the above-identified application on March 23, 2001, attached hereto is an English translation of the International Preliminary Examination Report, PCT Rule 72.2 (IPEA 409), which should be made of record in the present application.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. § 1.16 or under 37 C.F.R. § 1.17; particularly, extension of time fees.

Respectfully submitted,

BIRCH, STEWART, KOLASCH & BIRCH, LLP

By *Raymond C. Stewart* #43575
Raymond C. Stewart, #21,066 forRCS/GMD/jeb
2804-0102PP.O. Box 747
Falls Church, VA 22040-0747
(703) 205-8000